

<u>Single molecule in a tip-surface junction:</u> <u>Modeling and calculations in the context of</u> <u>non-contact AFM</u>



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Context of the ANR MOLSiC project

 \Rightarrow Substrate with a large band gap as silicon carbide (SiC) is chosen.

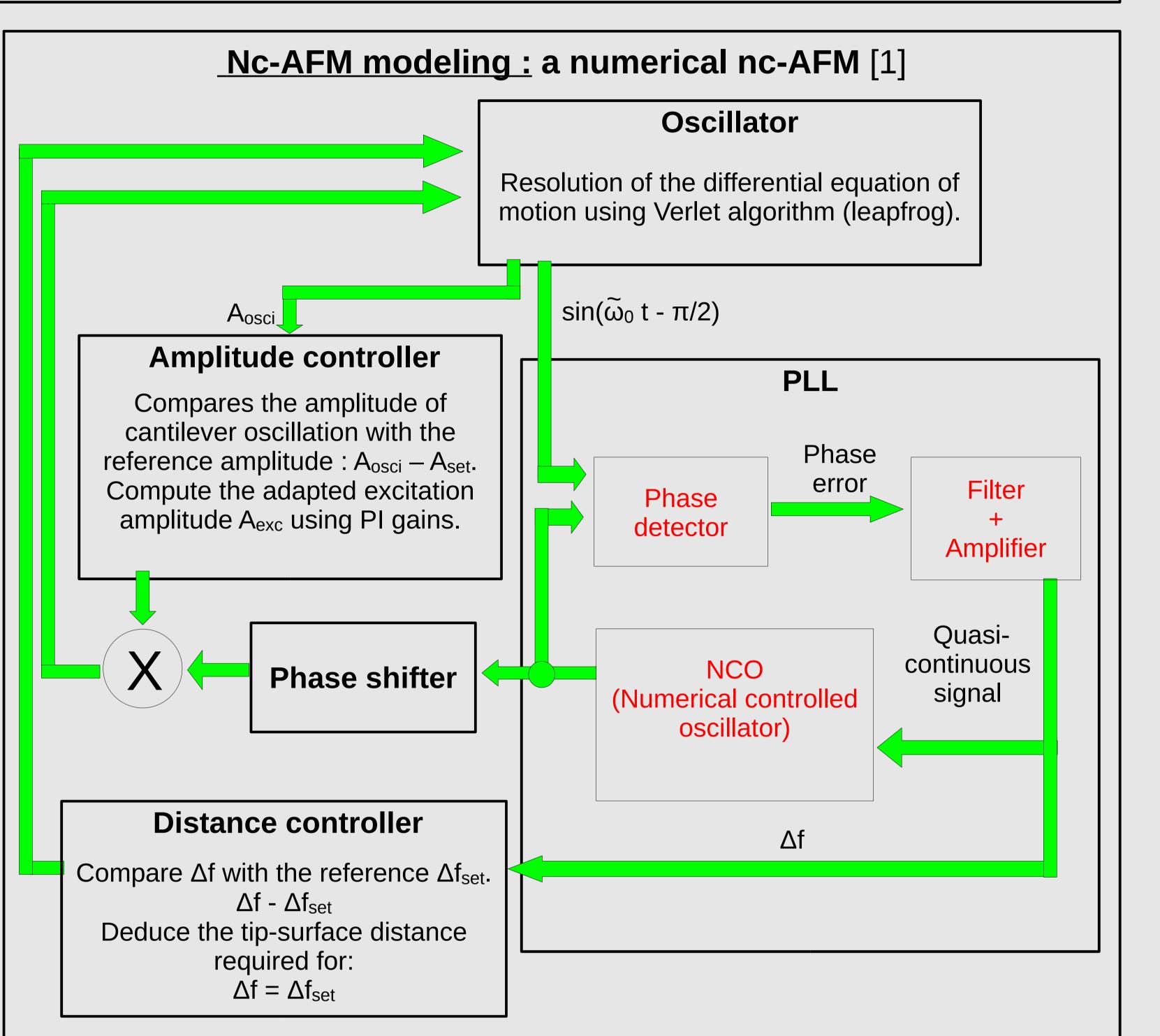
- STM study at low temperature is difficult without specific dopping. Frequency-Modulation nc-AFM is thus well adapted for the study of surface properties of SiC.
- ☆ In a first stage, modeling of the nc-AFM setup and simulations of its behaviour have been performed.

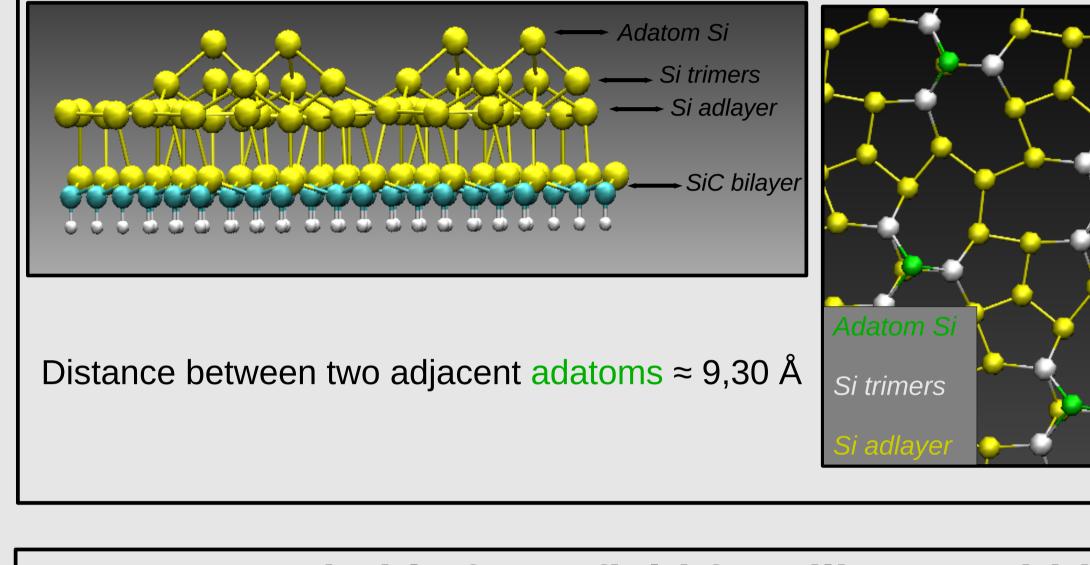
A This contribution of the MolSiC project is included in a consortium involving experimentalists of CEMES (Toulouse), IM2NP (Marseille), ICMO (Orsay) and theorititians of IS2M (Mulhouse).

SiC surface

A Silicon carbide is supposed to play an important role in electronics with high power, at high temperature and high frequency.

Numerous surface reconstructions have already been determined and offer many intrinsic properties.
 The consortium focuses on one of these reconstructions that is the 6H-SiC (0001) 3x3.





Suitable force field for silicon carbide

☆ Empirical interatomic potentiel :

$$E_V^{i-j} = \epsilon \left(1.84 * 10^5 \exp^{-\frac{12}{P}} - 2.25P^6\right)$$

$$evec \quad \epsilon = \sqrt{\epsilon_i \epsilon_j} \quad et \quad P = \frac{r_i + r_j}{R}$$

 $\Leftrightarrow \varepsilon_i, \varepsilon_j = \text{Hardness of atoms i et j (kcal/mole).}$

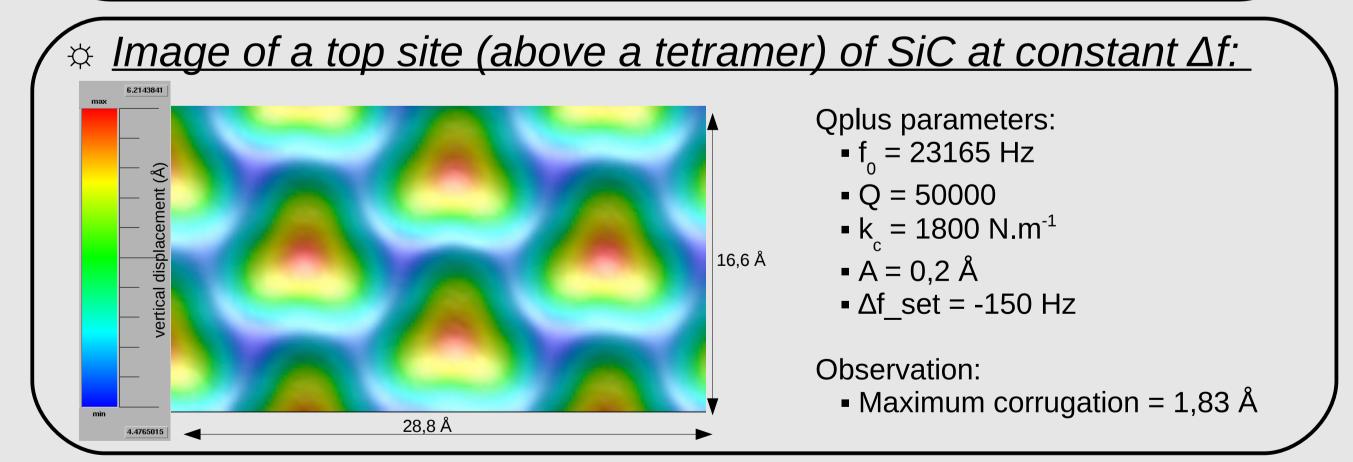
[1] L.Nony, A.Baratoff, D.Schär, O.Pfeiffer, A.Wetzel and E.Meyer, Phys. Rev. B 74, 235439 (2006)

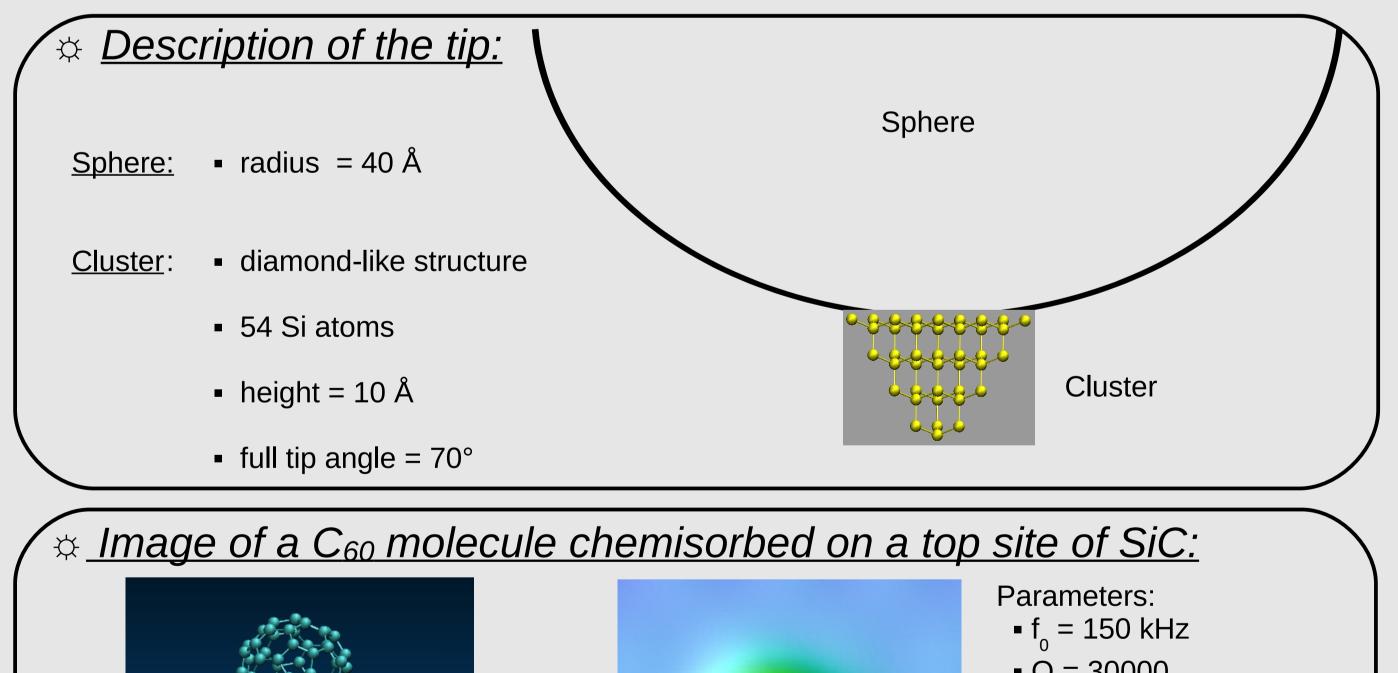
<u>First results</u>

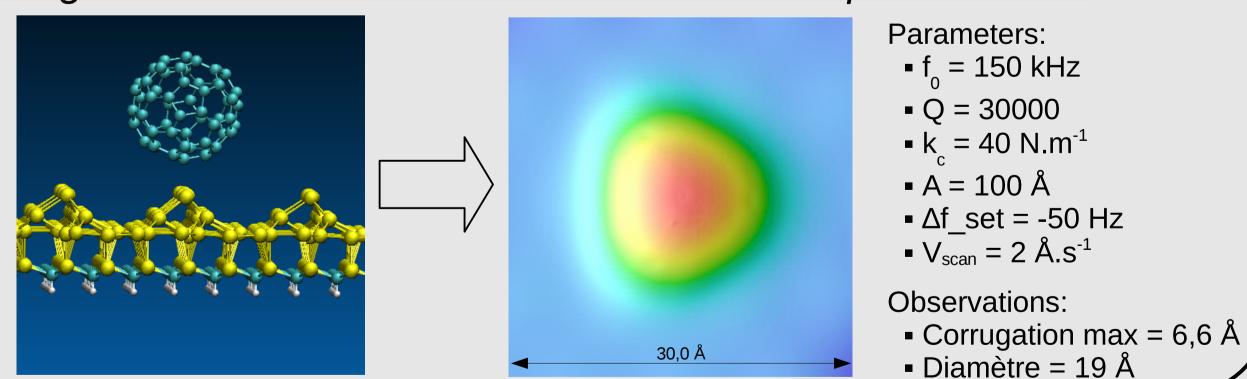
A Details about numerical nc-AFM:

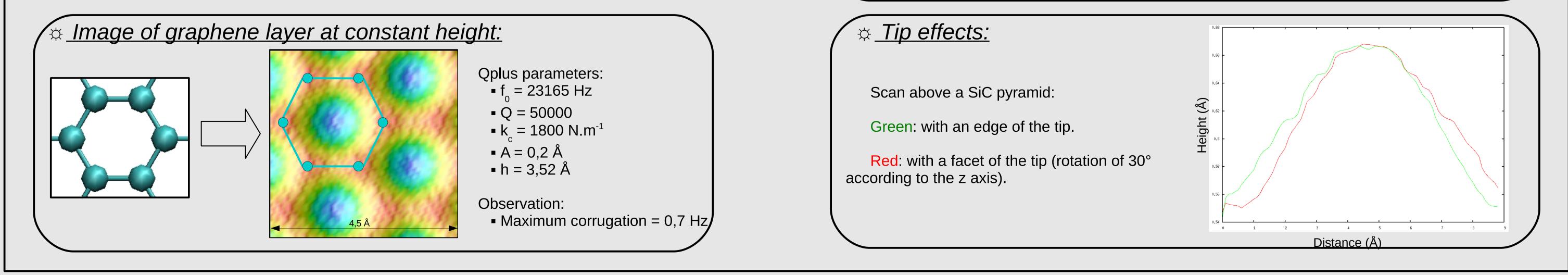
• The numerical nc-AFM is able to be used at large amplitude and at small amplitude, mimicking the **Qplus** setup.

 It can generate the topographic data set by operating in one of two modes: constant-height or constant-Δf mode.









<u>Outlook:</u>

A Calculation of relaxed functionalized molecules on a SiC surface by using molecular mechanics like procedure.

Study of their behavior when interacting with an AFM tip during scanning by introduction of molecular dynamics in the numerical code.